

Search Notes

Application/Control No.

10/775,072

Examiner

Edna Wong

Applicant(s)/Patent under
Reexamination

FAGRELL, MAGNUS

Art Unit

1795

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 435 | 91.2 | 11/9/2007 | EW |
| 204 | 157.15 | 11/9/2007 | EW |
| 204 | 157.6 | 11/9/2007 | EW |
| 204 | 157.68 | 11/9/2007 | EW |
| 204 | 157.71 | 11/9/2007 | EW |
| 204 | 157.72 | 11/9/2007 | EW |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|-----------------------------|-----------|------|
| Inventor Search | 11/9/2007 | EW |
| EAST | 11/9/2007 | EW |
| Consulted with Philip Leung | 11/9/2007 | EW |
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